Assessment of Elemental Impurities in Citric Acid

Element	Class	Potentially present?		Intentionally added?		Tested lot by lot?		Analytical method used (e.g., ICP-MS, ICP-OES)	Content measured or	Limit from material	Comments : i.e. frequency of testing/
		Yes	No	Yes	No	Yes	No	with Limit of Detection if available	range (μg/g)	specification, if available	test performed in- house or externally
Cd	1	Х			Х	Skip-lot		AAS	0.0012	* 0.5 ppm	In-house
Pb	1	Х			х	Skip-lot		AAS	0.0012	0.5 ppm	In-house
As	1	х			х	Skip-lot		AAS	0.0292	1.0 ppm	In-house
Hg	1	Х			х	Skip-lot		AAS	0.0006	1.0 ppm	In-house
Со	2A	Χ			Х	Annually		ICP	<0.46	* 5 ppm	Out-side
V	2A	X			Х	Annually		ICP	<1.176	* 10 ppm	Out-side
Ni	2A	X			Х	Annually		ICP	<1.49	* 20 ppm	Out-side
TI	2B		Х				Х	NA	NA	NA	NA
Au	2B		Х				Х	NA	NA	NA	NA
Pd	2B		Х				Х	NA	NA	NA	NA
lr	2B		Х				Х	NA	NA	NA	NA
Os	2B		Х				Х	NA	NA	NA	NA
Rh	2B		Х				Х	NA	NA	NA	NA
Ru	2B		Х				Х	NA	NA	NA	NA
Se	2B		Х				Х	NA	NA	NA	NA
Ag	2B		Х				Х	NA	NA	NA	NA
Pt	2B		Х				Х	NA	NA	NA	NA
Li	3				Х	Annually		ICP	<0,050	55 ppm	Out-side
Sb	3				Х	Annually		ICP	<0,0005	* 120 ppm	Out-side
Ва	3			1	Х	Annually		ICP	<0,030	* 140 ppm	Out-side



Мо	3	X	Annually	ICP	<0,015	* 300 ppm	Out-side
Cu	3	X	Annually	ICP	<0,002	* 300 ppm	Out-side
Sn	3	X	Annually	ICP	0,410	* 600 ppm	Out-side
Cr	3	X	Annually	ICP	<0,0005	* 1100 ppm	Out-side

^{*} Meet <USP 40 – Ch. 232> permitted concentration of Elemental Impurities for Individual Component Option

